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AMIDES OF HYALURONIC ACID AND THE DERIVATIVES THEREOF AND A PROCESS FOR THEIR **PREPARATION**

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An amide of hyaluronic acid or a derivative thereof which comprises at least one repetitive unit of general formula (I): wherein R = NR6R7, or alcoholic group of the aliphatic, aromatic, aryialiphatic, cycloaliphatic, heterocyclic series, OH, O-, alcoholic group of hyaluronic acid, amino group of descylated hyaluronic acid; R1, R2, R3, R4 = H, SO3-, acyl group derived from a carboxylic acid of the aliphatic, aromatic, aryialiphatic, cycloaliphatic, heterocyclic series, -CO-(CH2)2-COOY; Y = negative charge, or H; R5 = -CO-CH3, H, SO3-, acyl group derived from a carboxytic acid of the aliphatic, aromatic, arytaliphatic, cyclosliphatic, heterocyclic series, acylic group of hyaiuronic acid; R6 = is H or a sliphatic, aromatic, arylaliphatic, cyclosliphatic, or heterocyclic group, substituted or unsubstituted; R7 = is H or an alliphatic, aromatic, arylaliphatic, cyclosliphatic, or heterocyclic group, substituted or unsubstituted; wherein at least one of R or RS forms an amide group.

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